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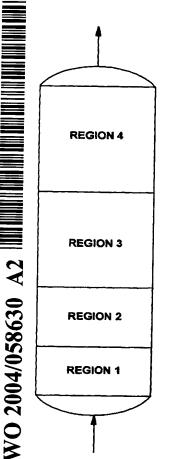
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(54) Title: PROCESS AND APPARATUS FOR HYDROGEN PURIFICATION



(57) Abstract: This invention discloses an optimum set of adsorbents for use in H_2 -PSA processes. Each adsorbent bed is divided into four regions; Region 1 contains adsorbent for removing water; Region 2 contains a mixture of strong and weak adsorbents to remove bulk impurities like CO_2 ; Region 3 contains a high bulk density (>38 lb_m/ft³) adsorbent to remove remaining CO_2 ; and most of CH_4 and CO present in H_2 containing feed mixtures; and Region 4 contains adsorbent having high Henry's law constants for the final cleanup of N_2 and residual impurities to produce hydrogen at the desired high purity.



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Declarations under Rule 4.17:

as to applicant's entitlement to apply for and be granted a patent (Rule 4.17(ii)) for the following designations AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, UZ, VC, VN, YU, ZA, ZM, ZW, ARIPO patent (BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PT, RO, SE, SI, SK, TR), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG)

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